	Application No.	Applicant(s)
Notice of Allowability	09/742,433	HIROKI, TOMOYUKI
	Examiner	Art Unit
	Rudy Zervigon	1763
The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS (herewith (or previously mailed), a Notice of Allowance (PTOL-85) of NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIC of the Office or upon petition by the applicant. See 37 CFR 1.313	OR REMAINS) CLOSED in this or other appropriate communica GHTS. This application is subje	s application. If not included ation will be mailed in due course. THIS
1. This communication is responsive to <u>January 5, 2005</u> .		
2. 🔀 The allowed claim(s) is/are <u>1-7</u> .		
3. The drawings filed on 29 July 2003 are accepted by the Examiner.		
 4. Acknowledgment is made of a claim for foreign priority undanals. All b) Some* c) None of the: Certified copies of the priority documents have Certified copies of the priority documents have Copies of the certified copies of the priority documents have Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" of noted below. Failure to timely comply will result in ABANDONMITHIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 	been received. been received in Application No uments have been received in the of this communication to file a re	o this national stage application from the
5. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.		
6. CORRECTED DRAWINGS (as "replacement sheets") must (a) including changes required by the Notice of Draftsperso 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1.1 each sheet. Replacement sheet(s) should be labeled as such in the	on's Patent Drawing Review (F Amendment / Comment or in t	he Office action of rawings in the front (not the back) of
7. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.		
Attachment(s) 1. Notice of References Cited (PTO-892) 2. Notice of Draftperson's Patent Drawing Review (PTO-948) 3. Information Disclosure Statements (PTO-1449 or PTO/SB/06 Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☐ Interview Sumn Paper No./Mai 8), 7. ☐ Examiner's Am	I Date

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DETAILED ACTION

Allowable Subject Matter

1. Claims 1-7 are allowed.

The following is a statement of reasons for the indication of allowable subject matter: 2. The closest prior art to the present invention is to Yoshinao Miyata (USPat. 5,992,974) and O'Neill, James F. et al (US 4,875,968 A) as detailed in the prior non-final action of October 19, 2004. Applicant's arguments filed January 5, 2005 are convincing. Specifically, none of the cited prior art teaches or suggests a top plate that is over-etched such that the resulting liquid chamber has a substantially rectangular shape. As stated in the prioraction: "Yoshinao Miyata does not teach over-etching Yoshinao Miyata's mask layer ("protecting layer", 41; column 8, lines 20-27) such that Yoshinao Miyata's liquid chamber (2, Figures 5(e)-5(g)) is formed beneath the mask layer.". The Examiner cited O'Neill, James F. et al as teaching a method of fabricating ink jet printheads where his etch resistane mask (25; Figure 5; column 6, lines 28-51) remains, after etching, to form a liquid chamber (24; Figure 5; column 6, lines 28-51) beneath the mask layer. However, as Applicant certifies in the response of January 5, 2005, and the examiner agrees: "there is no over-etching of the substrate under the mask while the mask is still present". As Applicant further certifies on page 6, O'Neill's Figure 5 structure would be geometrically different than O'Neill's Figure 5.

Conclusion

3. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Examiner Rudy Zervigon whose telephone number is (571) 272.1442. The examiner can normally be reached on a Monday through Thursday schedule from

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8am through 7pm. The official fax phone number for the 1763 art unit is (703) 872-9306. Any Inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Chemical and Materials Engineering art unit receptionist at (571) 272-1700. If the examiner can not be reached please contact the examiner's supervisor, Parviz Hassanzadeh, at (571) 272-1435.